

L Number	Hits	Search Text	DB	Time stamp
1	37	monitor\$4 near5 wafer near5 temperature same reactor	USPAT	2002/11/29 10:10
3	1	(monitor\$4 or measur\$4) and 6,214,116	USPAT	2002/11/29 10:21
5	1	(si or silicon) and 6,214,116	USPAT	2002/11/29 10:22
8	32	strip adj heater near5 coils	USPAT	2002/11/29 10:35
9	33	(silicon or si) and rotat\$4 near5 wafer\$1 and preheat\$4 near2 gas	USPAT	2002/11/29 10:41
-	1	isotherm\$4 and rotat\$4 near5 wafer\$1 and preheat\$4 near2 gas and velocity adj gradient	USPAT	2002/11/29 10:11
-	1	isotherm\$4 and rotat\$4 near5 wafer\$1 and preheat\$4 near2 gas	USPAT	2002/11/29 14:02
-	37	rotat\$4 near5 wafer\$1 and preheat\$4 near2 gas	USPAT	2002/11/29 10:40